

# **AN INVESTIGATION OF RF MEMS SWITCHES USED IN WIRELESS COMMUNICATION FOR AIRPLANE CONDITION MONITORING – Reliability and Materials Issues**

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**Center for Quality Engineering**



**FAA Centers of Excellence Meeting**  
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Project Start Date: September 6, 2001

Project Duration: 36 months

Technical Monitor: James Newcomb

# Condition Monitoring of Aircraft Structures



## Micro/Nano SENSORS

- Microcracks
- Temperature
- Lubricant Chemistry

## Wireless Communication TELEMETRY

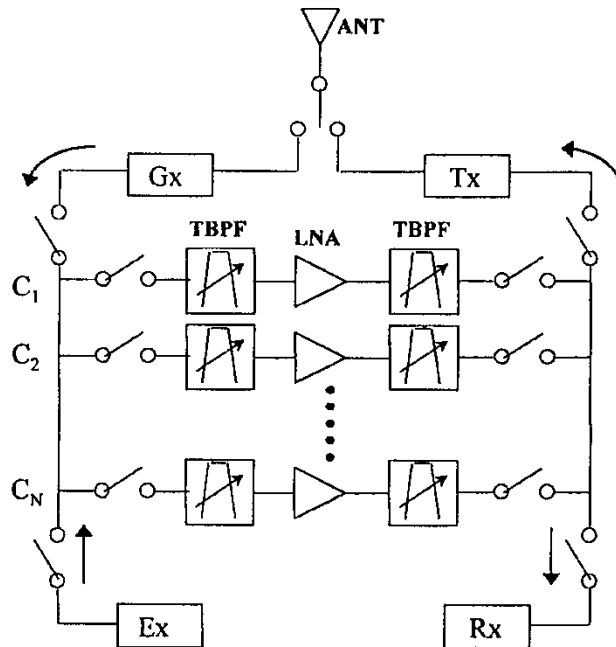
## Digital Signal Conditioning and Processing

Real Time

Storage in Memory

Periodic Maintenance

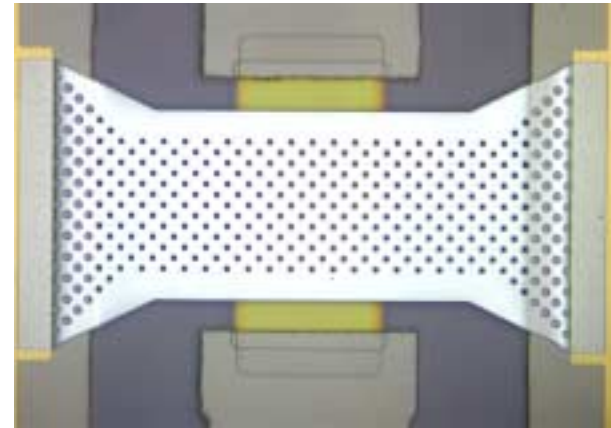
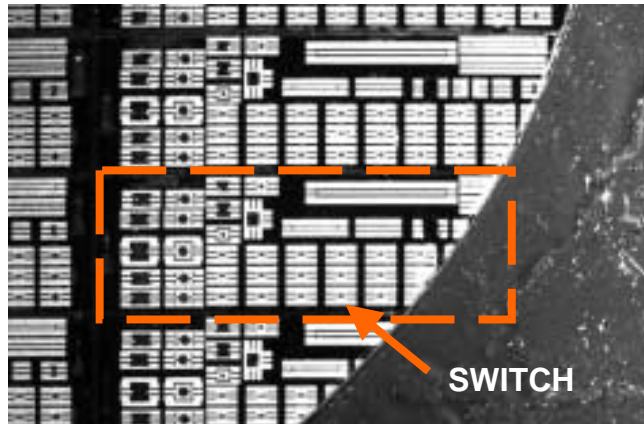
# RF-MEMS IN AIRPLANE CONDITION MONITORING



## ADVANTAGES:

- Multiple sensors communicating with a central unit
- Modular architecture
- Elimination of heavy wiring
- RF switches for: Signal routing
  - Digitized capacitor banks
  - Phase shifting networks

# MEMS for Wireless Communication



- **Applications of RF MEMS Switches**

- Wireless RF Communication, e.g., transfer of sensor array information to central unit or satellite-airplane communication for navigation control
- Programmable interconnects
- System network routers

- **Project Objectives**

- Better understanding of emerging NEMS/MEMS Technologies
- Improve reliability of Micro Switches made of Al alloys
- Transition technology to mass commercialization
- Train graduate students and post-docs in the emerging field of Nanotechnology

# Why Use Micro and Nano Switches

- **Why Micro and Nano Switches?**

- Major advantages over solid-state counterparts
  - lower insertion losses
  - true on/off state
  - low power
  - no spurious signals

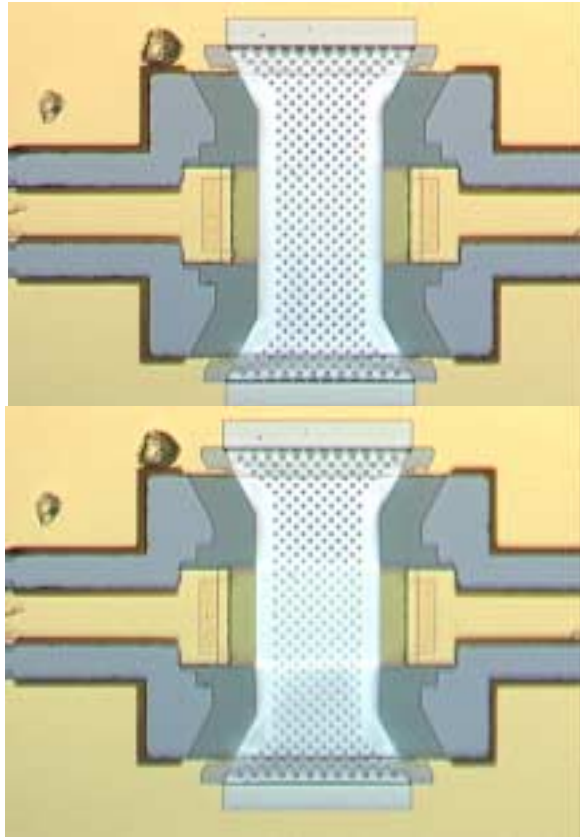
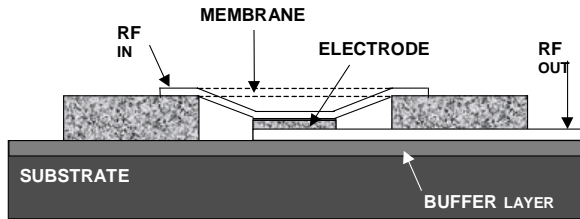
- **Major Commercialization Barriers**

- Assessing reliability at large number of actuation cycles
- Effect of temperature on switch response (-30 °C to 60 °C)
- Investigate stiction and relaxation of internal stresses critical to device functionality



# RF-MEMS Switch Operation

## MEMS Switch

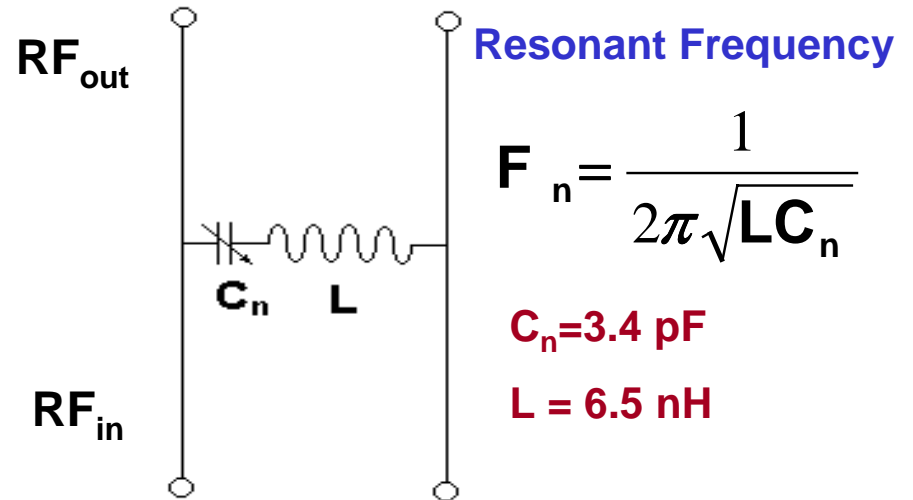


## • Switch Operation

- Electrostatic actuation pulls membrane to the bottom electrode
- Capacitive coupling allows RF signal to pass through the bottom RF path

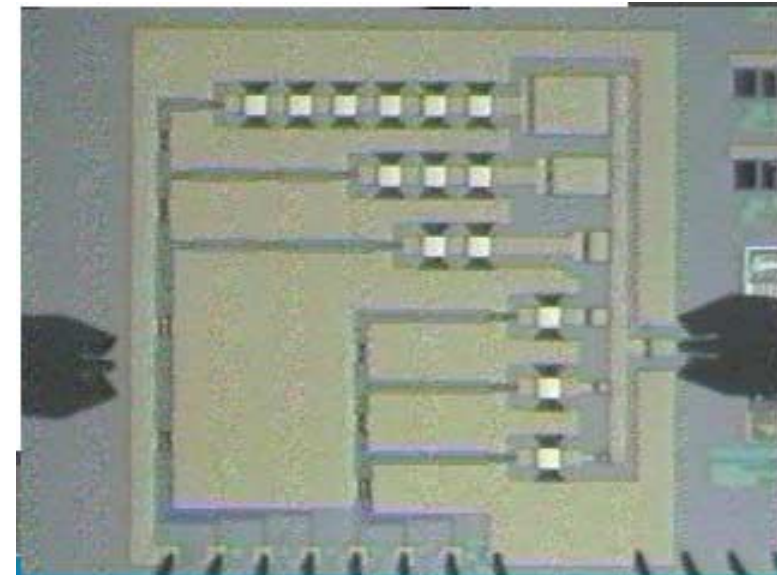
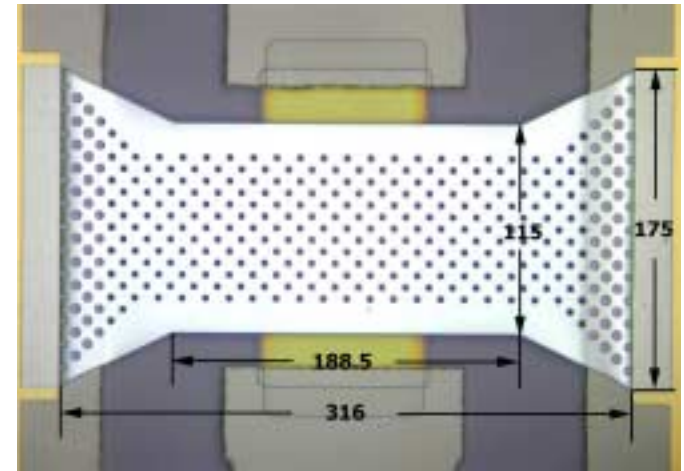
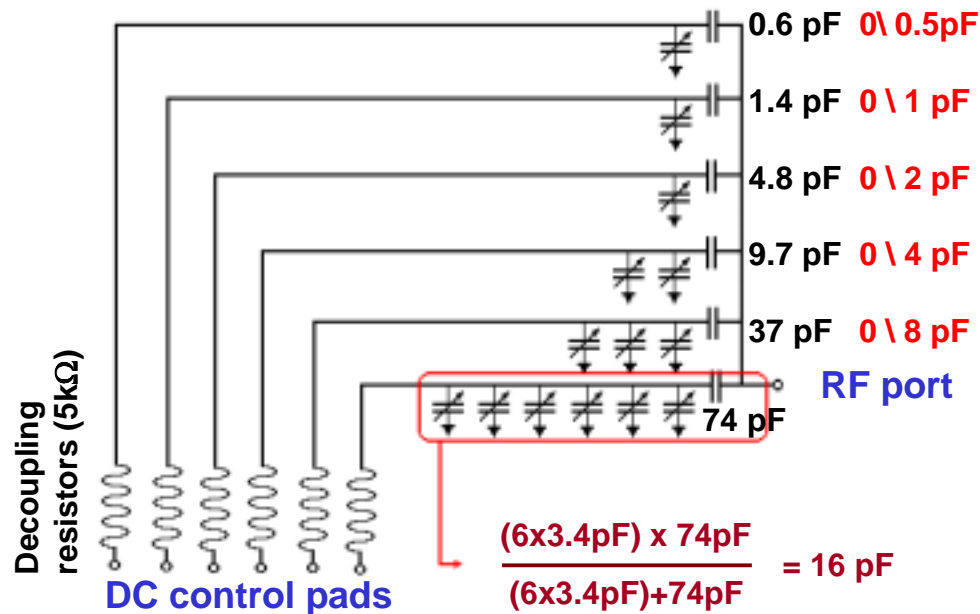
"Off" state

"On" state



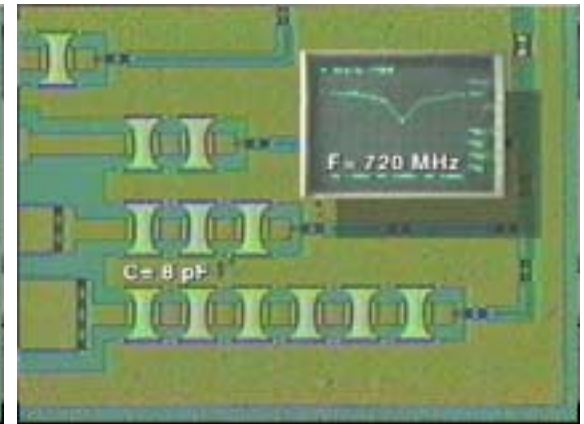
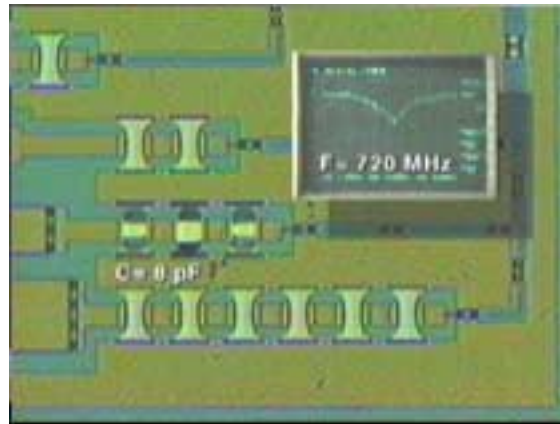
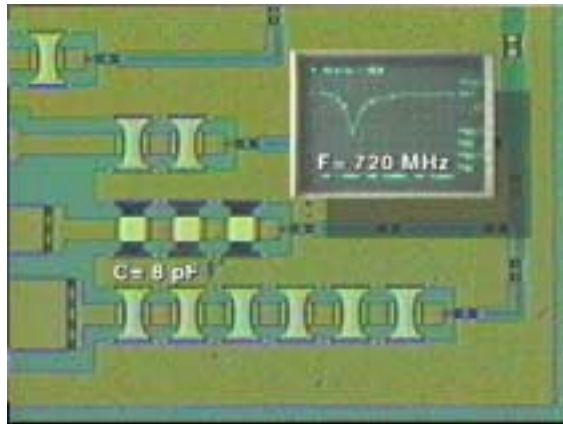
# RF Switch Applications

## Tunable Capacitor

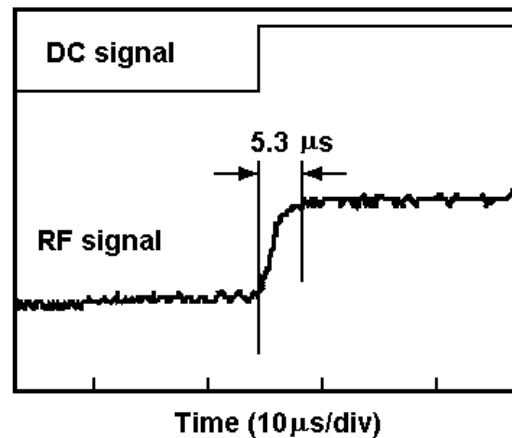
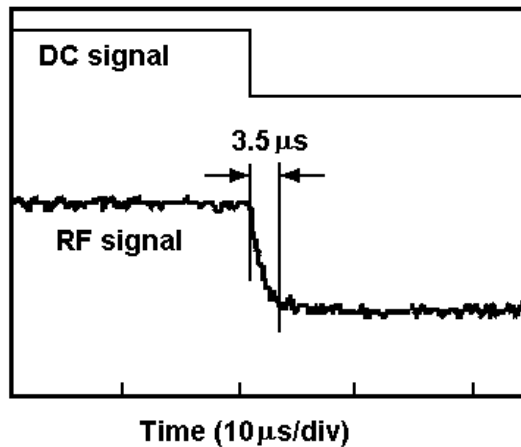


Goldsmith et al., Int. J. of RF and Microwave Computer Aided Engineering, Vol. 9, No. 4, pp. 362-374,1999.

# TIME RESPONSE AND EFFECT ON SIGNAL



Switching the DC actuation off/on, not all the membranes recover simultaneously to the initial shape.



Switching time:  $\sim 15 \mu\text{s}$   
(Safe estimate)



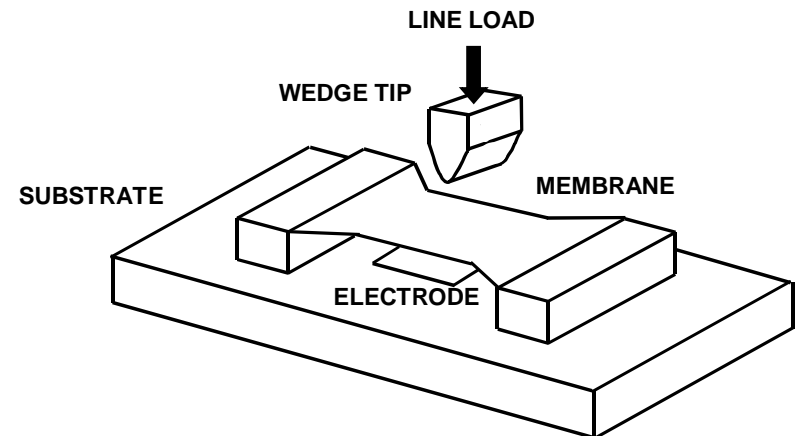
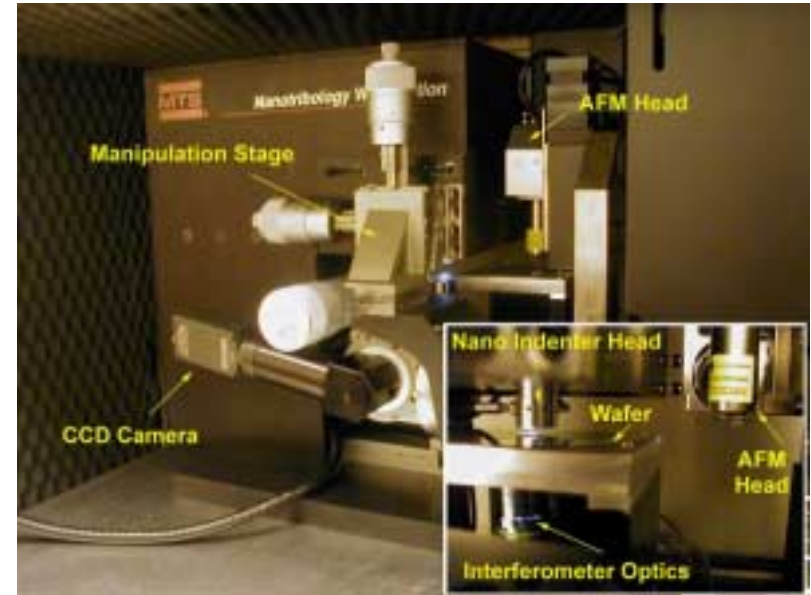
# MEMS Switch Reliability Testing

- **On-Chip Testing**

- Deflect membrane with nanoindenter
- Special wedge tip allows for uniform loading
- Temperature testing in environmental chamber
- Load-displacement curves are obtained

- **What do we learn?**

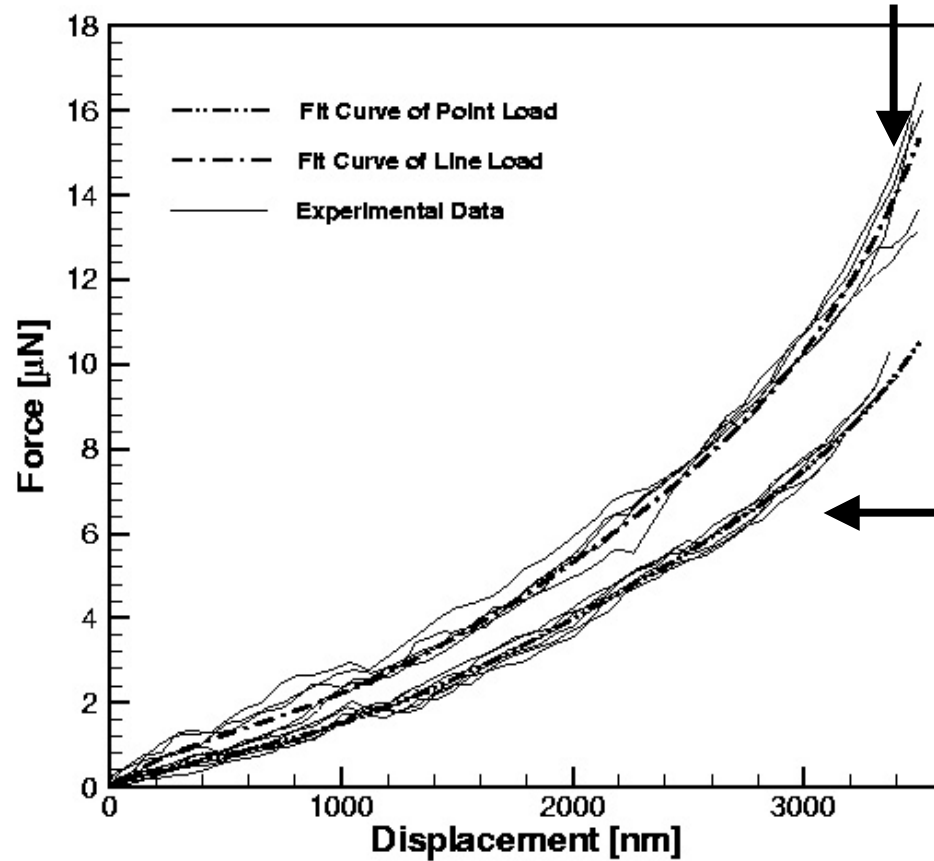
- $E$ ,  $\sigma_o$ , and shape as a function of temperature



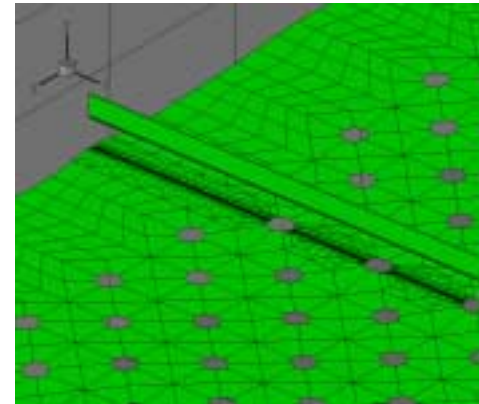
**Membrane Deflection Experiment**

# Experimental Results

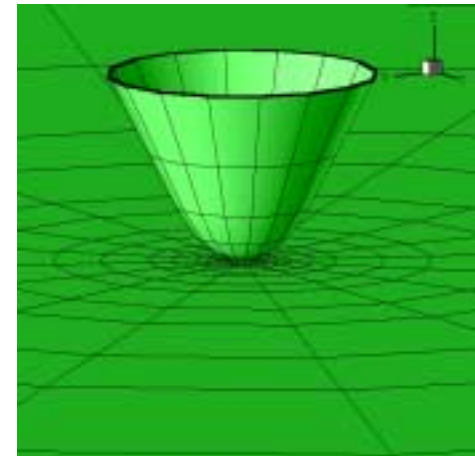
## Repeatability



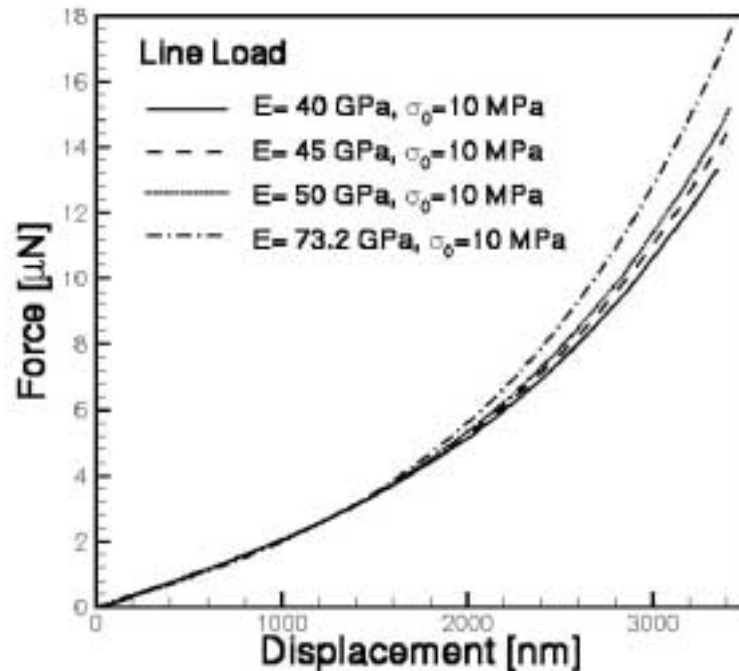
## Wedge Tip



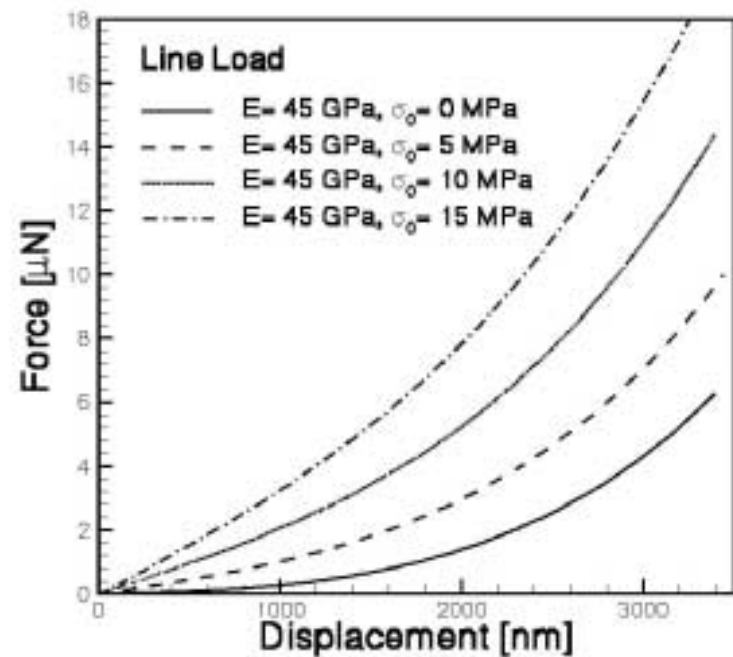
## Berkovich Tip



# Numerical Simulations



**Effect of Young's modulus on load-deflection response**



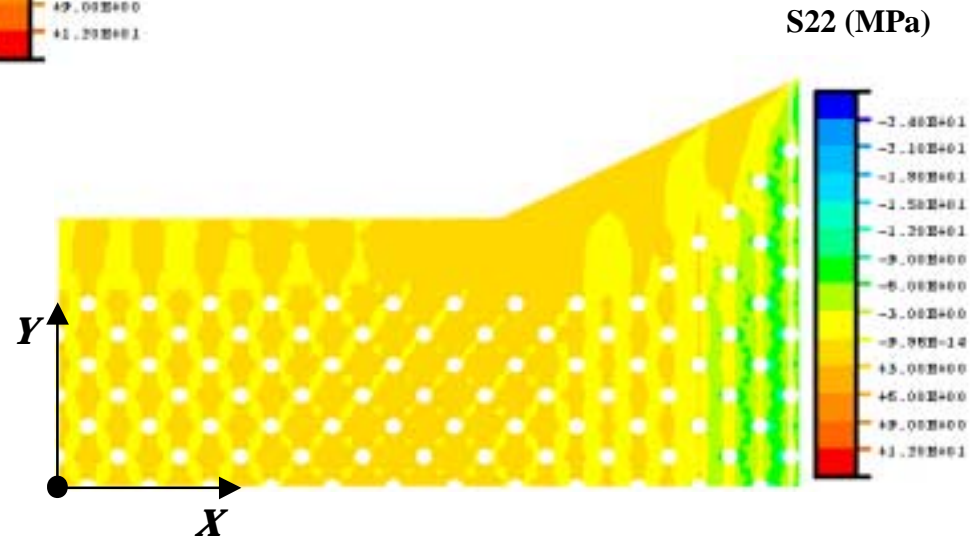
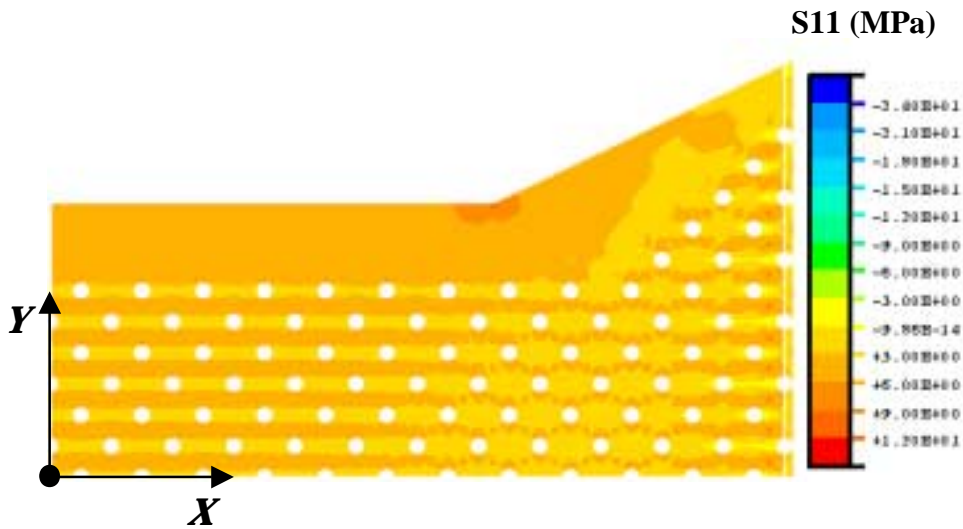
**Effect of residual stress on load-deflection response**

# Residual Stress Distribution

- Residual Stress Identification

## Stress Contours

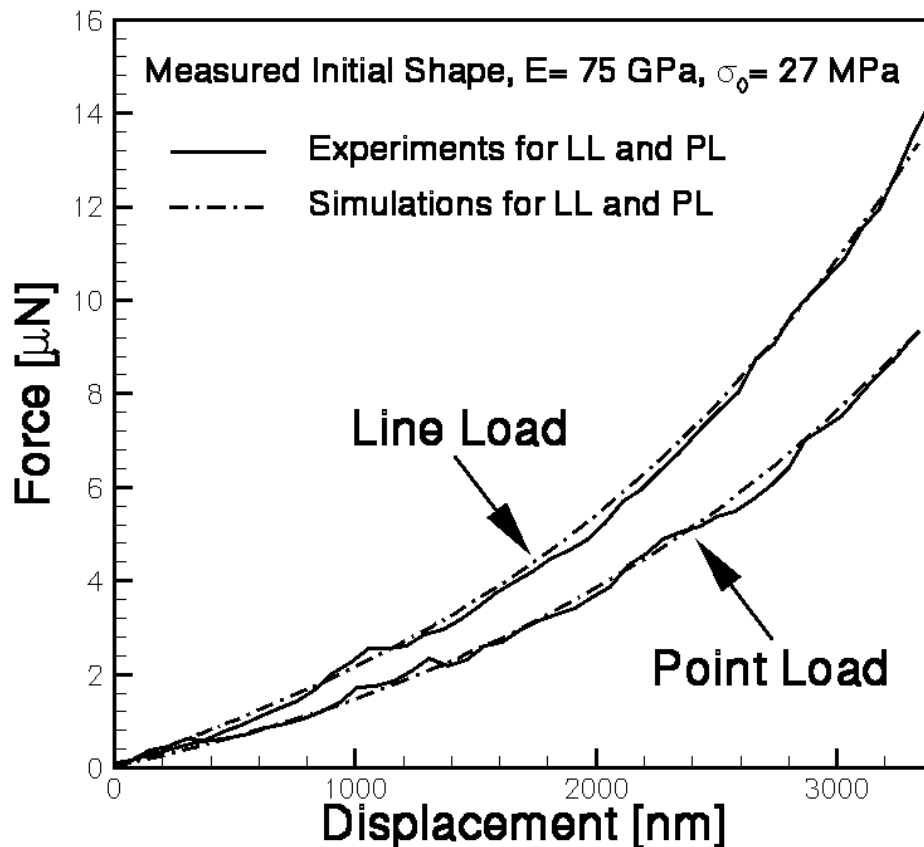
Student: Yong Zhu



# Identification at Room Temperature

- **Results of MDE Identification**

- Experiments
- FEM simulations accounting for shape, E and residual stress identification



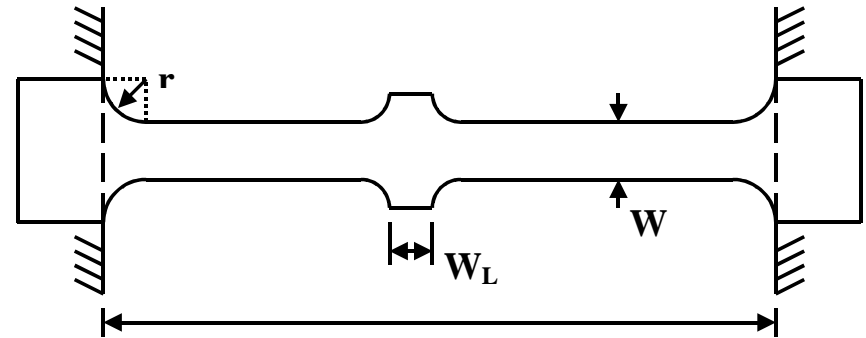
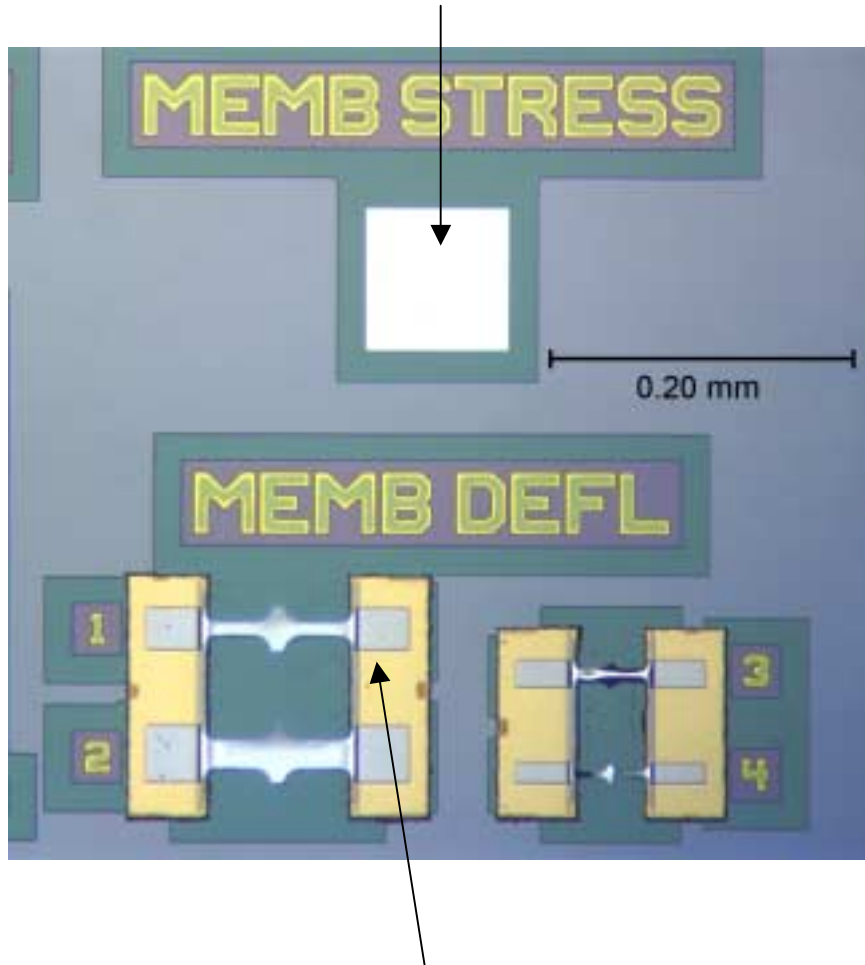
**Comparison between experimental measurements and numerical simulations for two indenter geometries. Good agreement is observed for identified set of parameters.**

H.D. Espinosa, Y. Zhu, M. Fischer, and J. Hutchinson, "An Experimental / Computational Approach to Identify Moduli and Residual Stress in MEMS RF-Switches," to appear in *Experimental Mechanics*, 2002.

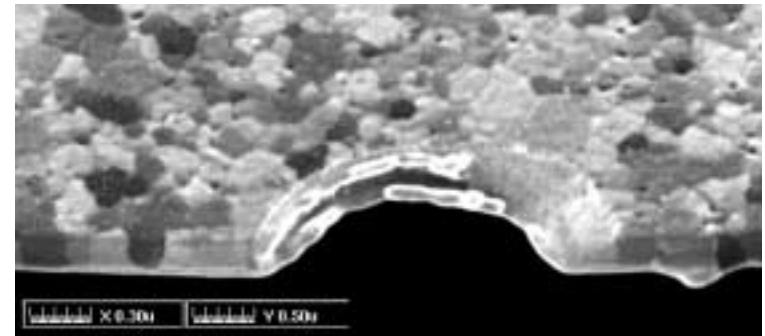


# Specimen Shape to Investigate Temperature Effects

## Nanoindentation Pad

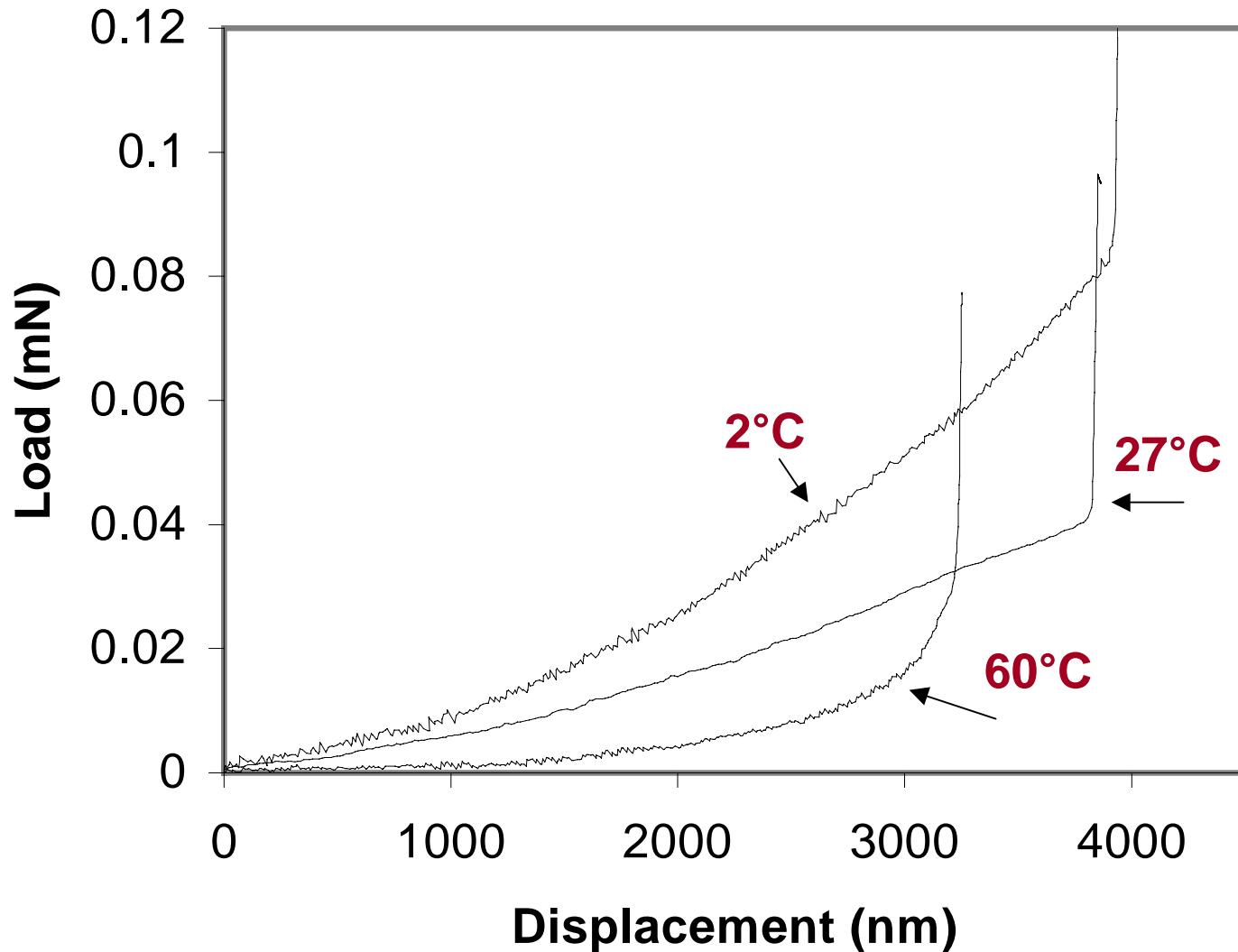


Sample	$L$ ( $\mu\text{m}$ )	$r$ ( $\mu\text{m}$ )	$W$ ( $\mu\text{m}$ )	$W_L$ ( $\mu\text{m}$ )
1	100	10	10	10
2	100	10	20	10
3	50	5	10	5
4	50	5	5	5

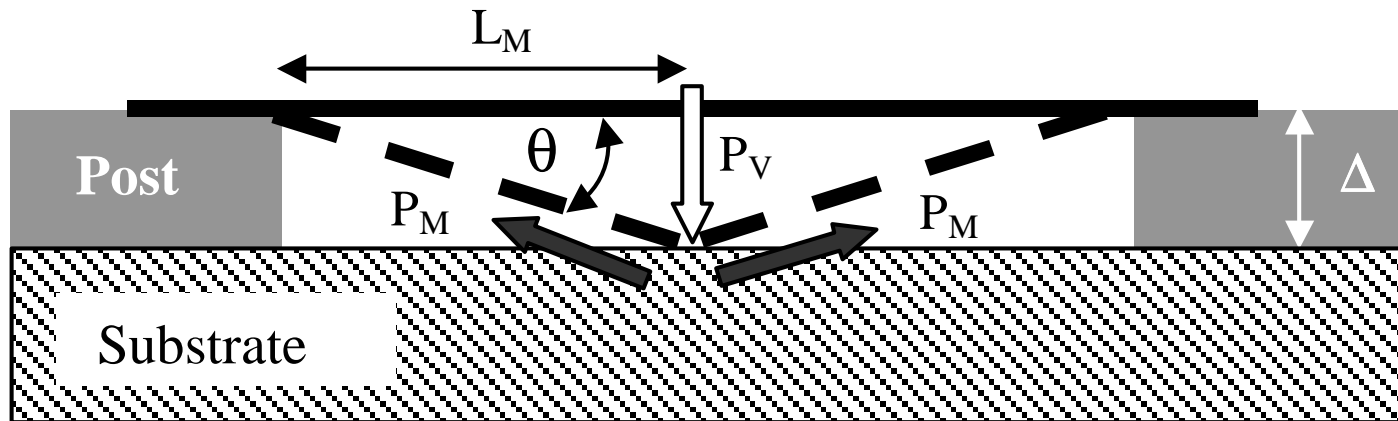


## Double Dog-Bone, Freestanding MDE Specimens

# Load – Deflection Curves at Different Temperatures



# Stress and Strain Calculations



## Cauchy Stress

$$\tan \theta = \frac{\Delta}{L_M} \quad P_M = \frac{P_V}{2 \sin \theta}$$

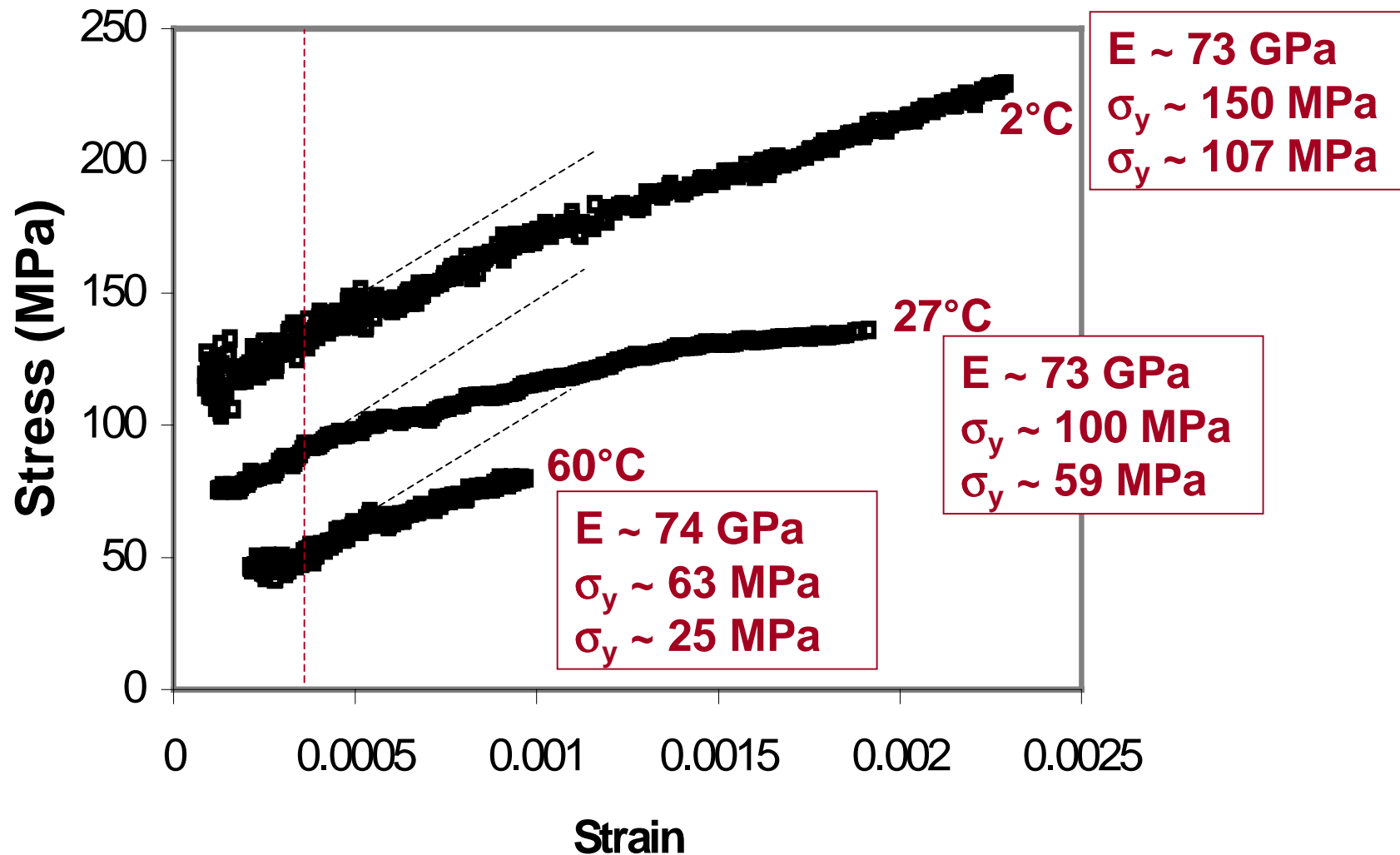
$$\sigma(t) = \frac{P_M}{A}$$

## Strain

$$\varepsilon(t) = \frac{\Delta L_M}{L_M} = \frac{\sqrt{\Delta^2 + L_M^2}}{L_M} - 1$$

# Stress- Strain Curves

## Combined AFM/Nanoindenter



# NEMS RF- Switch Concept

- **CNT Switch Operation**

- Electrostatic activation pulls CNT to the bottom electrode

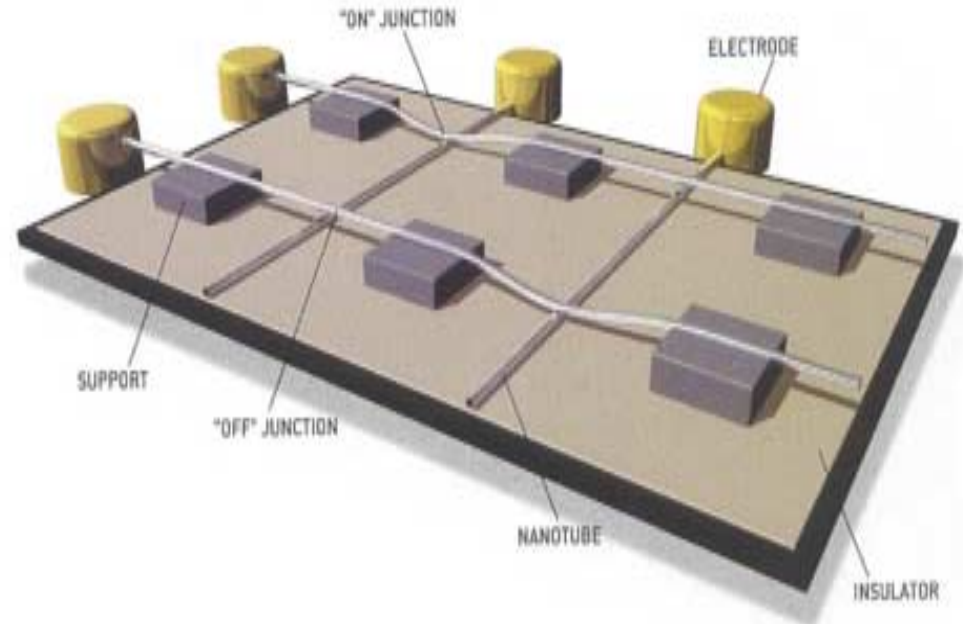
- **NEMS Switch Advantages**

- Time response
- Density of states

- **Major Challenges**

- Nanofabrication
- Electro-mechanical characterization

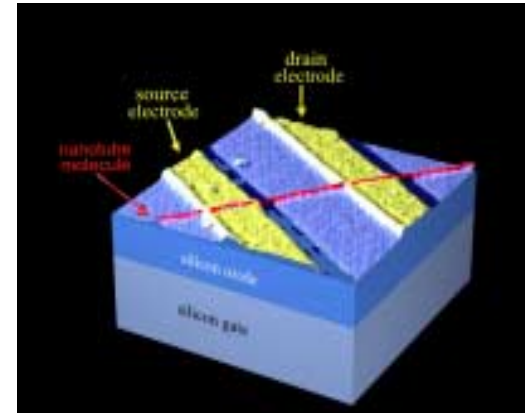
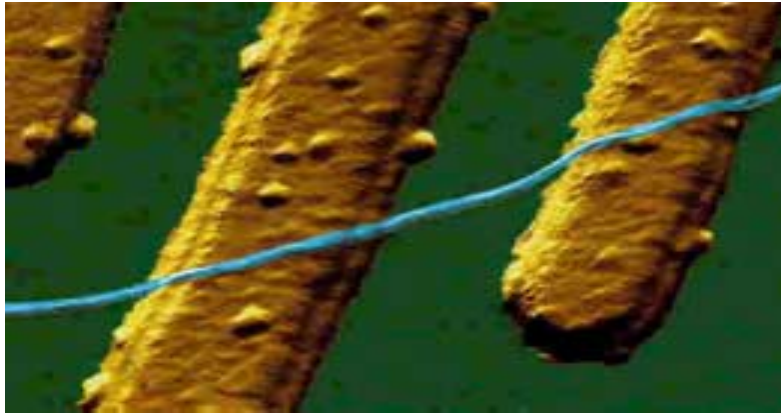
## Carbon Nanotube NEMS Switch



Charles Lieber, "The incredible Shrinking Circuit," Scientific American, September, 2001

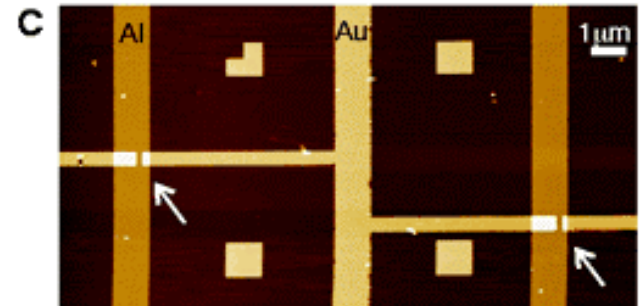
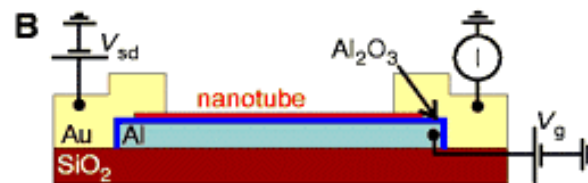
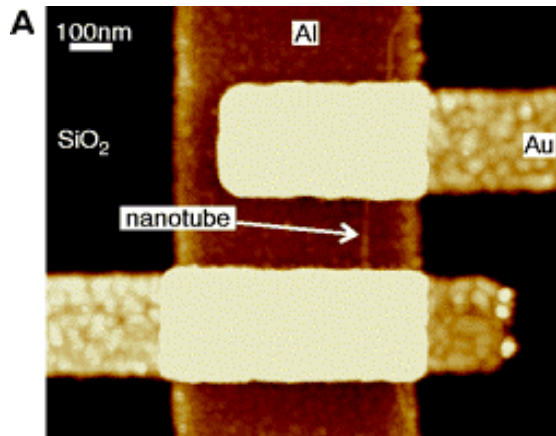


# Recent Developments In Nanoelectronics



**First CNT Single-Electron-Transistor (SET) by depositing of a CNT on top of Au electrodes with SiO<sub>2</sub> as the dielectric layer. Local barrier induced with atomic force microscope (AFM)**

*Dekker, et al, Science, 2001, 293, 76*



**Logic Circuit with Carbon Nanotube Transistor**

*Adrian Bachtold, et al, Science, 2001, 294, 1317*

# RF-NEMS Switch Testing

Student: C. Ke

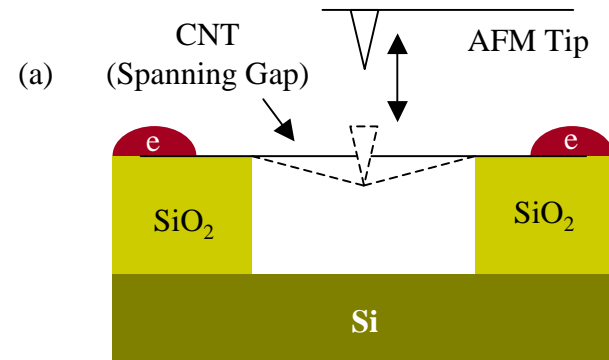
- **On-Chip Testing**

- Deflect CNT with an AFM Tip (a)
- Deflect CNT with a Nanoindenter (b)
- Obtain load-displacement curves
- Measure electrical properties under load and deformation

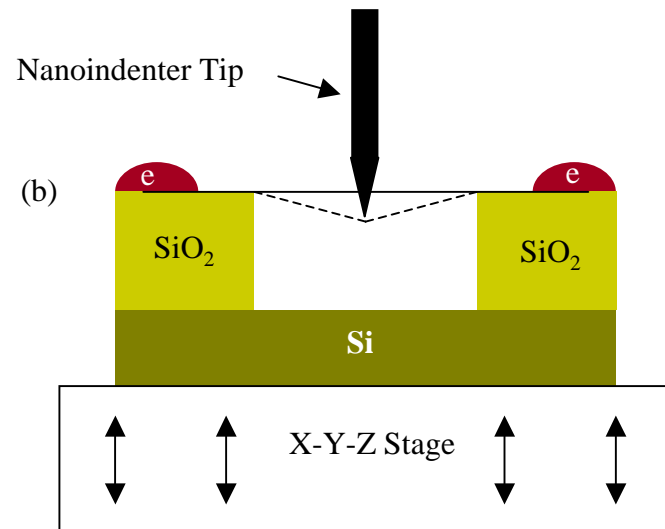
- **What do we learn?**

- Young's modulus ( $E$ )
- Changes in conductivity as a function of mechanical deformation

## CNT Deflection Experiment



“e” denotes electrodes



# Milestones

- **Quarter 1- 4**  
Initiate Manufacturing of RF-MEMS switches in collaboration with Raytheon System Company. Initiate design of membrane deflection experiment apparatus for low and high temperature testing.
- **Quarter 5-8**  
Obtain Load-Deflection data on aluminum alloy membranes in the temperature range  $-2\text{ }^{\circ}\text{C}$  to  $60\text{ }^{\circ}\text{C}$ . Perform numerical simulations of the membrane deflection experiments to identify moduli and residual stress states as a function of temperature.
- **Quarter 9-10**  
Start experiments to characterize nano-carbon tubes electromechanical response by nanoindentation testing.
- **Quarter 11**  
Finalize assessment of NEMS actuation and impacts on wireless communication technology for the proposed applications of interest.
- **Quarter 12**  
Deliver final project report to FAA.